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City: Hong Kong
Country: China

Federal Communications Commission
Authorization and Evaluation Division

Confidentiality Request

Pursuant to 47 CFR Section 0.457 and 0.459, the applicant hereby requests non-disclosure and confidential treatment of the following materials submitted in support of FCC certification application for

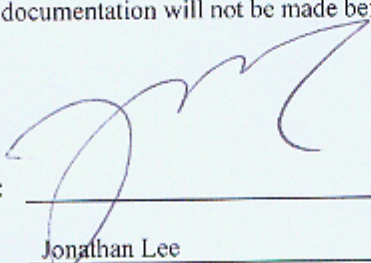
FCC ID: XQN-BRC100I

- ☒ Bill(s) of Material
- ☒ Block Diagrams
- ☒ Operational Description
- ☒ Schematic Diagrams

The above materials contain trade secrets and proprietary information not customarily released to the public. The public disclosure of these matters might be harmful to the Applicant and provide unjustified benefits to its competitors.

The Applicant understands that pursuant to Rule 0.457, disclosure of this Application and all accompanying documentation will not be made before the date of the Grant for this application.

Sincerely,

Signature: 
Name: Jonathan Lee
Title: CEO
Date: 30 January 2012